

## **COPY OF PAPERS ORIGINALLY FILED**

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Thomas A. Figura, Kevin Donohoe, & Thomas Dunbar

Serial No.: 09/470,650

Filed:

December 22, 1999

Title: USE OF A PLASMA SOURCE TO FORM A LAYER

DURING THE FORMATION OF A SEMICONDUCTOR DEVICE

Group Art Unit: 2829

Examiner:

Lisa Kilday

Atty. Docket:

94-0280.04

RESPONSE TO THE OFFICE ACTION DATED MARCH 15, 2002

Commissioner for Patents Washington, D.C. 20231

Dear Sir:

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Commissioner for Patents

Washington, DC 202

Applicants herein respond to the Office Action dated March 15, 2002.

## **REMARKS**

Claims 1-8, 10-14, 19, 23-24, 29-32, and 36-43 are pending.

Claims 1-8, 10-14, 19, 23-24, 29-32, and 36-43 are rejected.

Applicants request reconsideration of claims 1-8, 10-14, 19, 23-24, 29-32, and 36-43.

## I. Rejection of claims under §112

The Examiner rejected claims 1-8, 10-14, 19, 23-24, 29-32, and 36-43 under §112 ¶1, arguing that Applicants should demonstrate the Specification's disclosure of a reasonable number of species representing "today's broad genus encompassing the